High Precision Optical Filters by ion-beam sputtering(IBS)

The ion-beam sputtering method deposits thin films of a target material onto the surface of a circuit board.

It demonstrates an excellent performance in multi-layer coating application because a growing film keeps its surface flat and smooth.

Taking advantage of this property, this method can produce high-precision filters demanded in the most advanced technological fields.

<u>Application</u>: Laser, Fluorescence spectroscopy and microscopy, Cavity ring down spectroscopy and so on





